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RSC Advance – Electronic Supplementary Information



Fig.1S Wide angle XRD patterns of SPC and MMT.



Fig.2S Low angle XRD patterns of Ni^{II}-SPCs.



Fig.3S SEM images of the compared samples: (A) Ni⁰/SPC-6, (B) Ni⁰/SPC-3, (C) Ni⁰/SPC-2, (D) SPC.



Fig.4S FTIR patterns for (A) Ni^{II}-SPC-6, (B) Ni^{II}-SPC-3, (C) Ni^{II}-SPC-2, (D) SPC, (E) MMT.

Fig. 4S shows the FTIR spectra of the products in the range of 4000 - 450 cm⁻¹. The strong and wide bands around 1200 - 1000 cm⁻¹ are associated to the asymmetric Si–O stretching modes. The Ni^{II}-SPCs and SPC have the much sharper bands at 1082 cm⁻¹ than natural montmorillonite, this suggests that the crystallinity of the particles increased and the particles became more compact.^[32]

The characteristic band of Si-O-Si in 809 cm⁻¹ could be observed for SPC. However, the band of Ni^{II}-SPCs at 809 cm⁻¹ has a slight red-shift to 803 cm⁻¹. This may have been due to an interaction between the nickel atoms and silicon (forming Ni-O-Si bonds)^[40,42]. And these results indicate that there is silica structure had been planted into the interlayer of clay. Moreover, a strong sharp band at 1385 cm⁻¹ exists at the FTIR spectra of Ni^{II}-SPC-6, Ni^{II}-SPC-3 and Ni^{II}-SPC-2. With the incorporation of Ni (II) into the gallery silica framework, the intensity of 1385 cm⁻¹ bands increase with the increase of molar of nickel nitrate hexahydrate ammonia solution during graft process. Furthermore, the intensity of the band at 1385 cm⁻¹ increases with the nickel content increases, which is usually taken as proof of the Ni–O–Si in the gallery frame structure.



Fig. 5S TEM images of (A) Ni⁰-SPC-6 and (B) Ni⁰/SPC-6 after five times of catalytic reaction, respectively.